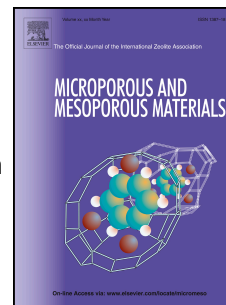


# Accepted Manuscript

Phonons in mesoporous silicon: The influence of nanostructuring on the dispersion in the Debye regime

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PII: S1387-1811(17)30064-1

DOI: [10.1016/j.micromeso.2017.02.023](https://doi.org/10.1016/j.micromeso.2017.02.023)

Reference: MICMAT 8133

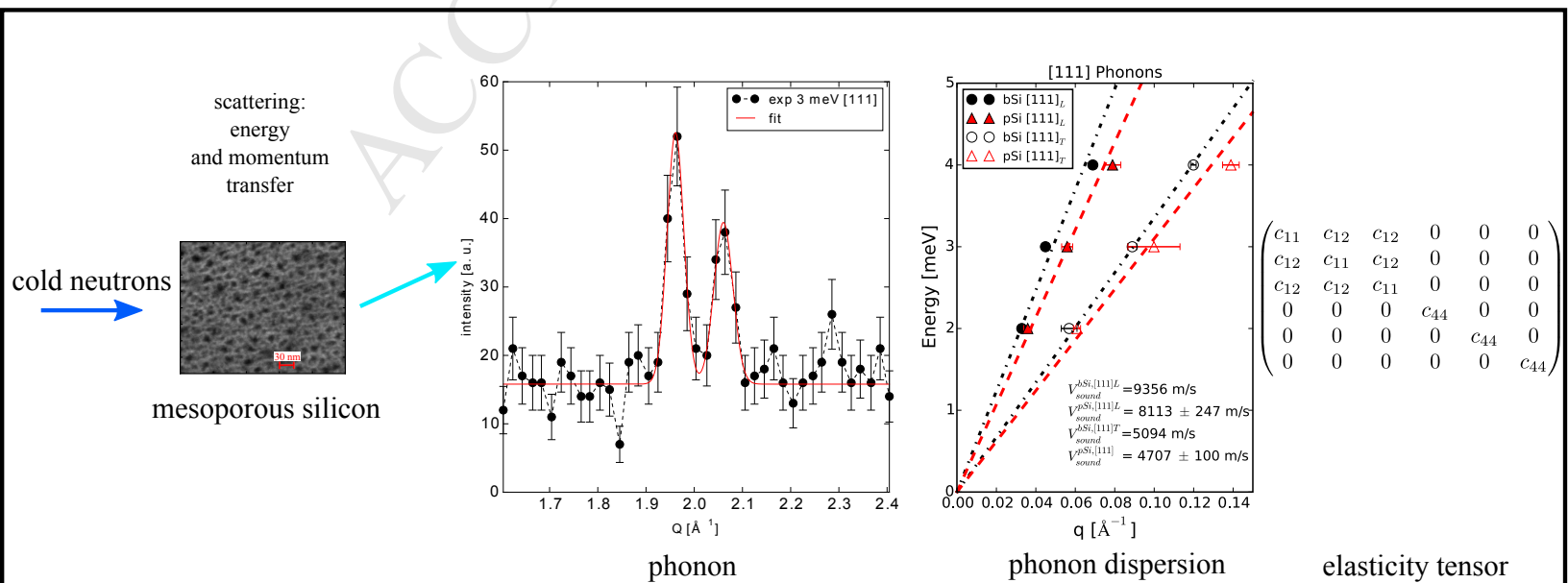
To appear in: *Microporous and Mesoporous Materials*

Received Date: 11 January 2017

Accepted Date: 6 February 2017

Please cite this article as: T. Hofmann, D. Wallacher, R. Toft-Petersen, B. Ryll, M. Reehuis, K. Habicht, Phonons in mesoporous silicon: The influence of nanostructuring on the dispersion in the Debye regime, *Microporous and Mesoporous Materials* (2017), doi: 10.1016/j.micromeso.2017.02.023.

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